



Simple solution route to uniform MoS₂ particles with randomly stacked layers

Qing Li^{a,*}, Ming Li^b, Zhiqian Chen^a, Chunmei Li^a

^a*School of Materials Science and Engineering, Southwest Normal University, Chongqing 400715, PR China*

^b*School of Chemistry and Chemical Engineering, Southwest Normal University, Chongqing 400715, PR China*

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Abstract

MoS₂ particles of uniform size (ca. 70 nm) consisting of random and loosely stacked layers have been synthesized from hydrazine solution with (NH₄)₂Mo₃S₁₃ as the precursor at 180 °C for 16 h under hydrothermal conditions. The particles were characterized by X-ray diffraction (XRD), X-ray photoelectron spectroscopy (XPS) and high-resolution transmission electron microscopy (HREM). The influences of reaction conditions are discussed while a mechanism is proposed to explain the formation of this peculiar morphology.

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1. Introduction

There has been considerable interest in the transition metal dichalcogenide layered compounds, a group of anisotropic materials with strong bonding within the layers and weak interlayer interactions [1]. As one of the members of this family, MoS₂ has numerous applications as a hydrodesulfurization catalyst [2], as a solid-state lubricant [3], as an electrode in high-energy density batteries [4], and as an intercalation host to form new materials [5].

Conventionally, the synthesis of MoS₂ powders involves thermal decomposition of ammonium tetrathiomolybdate [6], or by the reaction of stoichiometrically mixed molybdenum and sulfur powders in vacuum at high temperature [7]. Metathesis reactions [8], gas-phase decomposition of Mo(CO)₆ in the presence of H₂S [9], and even sonochemical [10] or γ -irradiation methods [11] to produce finely dispersed MoS₂ have been explored. Afanasiev et al. [12] synthesized single-molecular-layer (SML) MoS₂ in aqueous solution in the presence of an organic surfactant. Recently, Feldman et al. [13]

* Corresponding author. Tel.: +86-23682-53929; fax: +86-2368-254373.

E-mail address: qli@swnu.edu.cn (Q. Li).

reported that nested inorganic fullerene-like MoS₂ could be prepared from the reaction between MoO₃ and H₂S in a H₂ atmosphere at about 800 °C. Liao et al. [14] have also fabricated MoS₂ fibers at room temperature.

Herein, we report the preparation and characterization of 2H-MoS₂ in a new morphological structure. The products were uniform particles that exhibited randomly stacked layers at high magnification.

2. Experimental

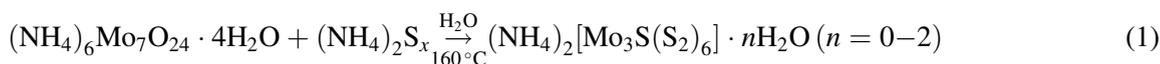
All the reagents used were of analytical grade purity (Shanghai Chemistry Co., Ltd.) and were used without further purification.

The precursor (NH₄)₂Mo₃S₁₃ was prepared according to the literature [15]. The preparation process of MoS₂ was as follows: 0.5 g (NH₄)₂Mo₃S₁₃ and 10 ml hydrazine monohydrate (N₂H₄·H₂O) were put in a Teflon-lined stainless steel autoclave of 50 ml capacity (caution: excess hydrazine is dangerous because of the sudden production of gas in a confined space). Distilled water was used to fill the tank to 60% of the total volume. The autoclave was maintained at 180 °C for 16 h, then allowed to cool to room temperature. The resulting dark-gray powders were filtered and washed with distilled water and anhydrous ethanol. Then the final products were dried in a vacuum at 50 °C for 5 h. The solids were annealed for 2 h under a Ar flow at 300, 450, and 600 °C, respectively.

Phase identification was performed by X-ray powder diffraction (XRD) using an MXP18AHF X-ray diffractometer (MAC Science Co., Ltd.) with Cu Kα radiation (λ = 1.54056 Å). The samples were scanned at a scanning speed of 0.02 s⁻¹ in the 2θ range of 5–65°. X-ray photoelectron spectroscopy (XPS) spectra were recorded with a VGESCALAB MKII X-ray photoelectron spectrometer, using nonmonochromatic Mg Kα X-ray as the excitation source. Morphology and size information of the precipitates were observed on a Hitachi Model H-800 transmission electron microscopy (TEM), using an accelerating voltage of 200 kV.

3. Results and discussion

The reactions involved here can be described as follows:



First, (NH₄)₆Mo₇O₂₄·4H₂O reacted with (NH₄)₂S_x in aqueous solution, forming the precursor (NH₄)₂Mo₃S₁₃ [15]. Second, (NH₄)₂Mo₃S₁₃ was reduced by hydrazine at 180 °C and finally MoS₂ precipitated from the solution. As a reducing agent, hydrazine is volatile and easily decomposes. It can decompose thermally to produce N₂, H₂ and NH₃ (N₂H₄ → (1/2)N₂ + NH₃ + (1/2)H₂) [16]. Thus the as-produced H₂ could react with the precursor.

The TEM image of the sample prepared at 180 °C is shown in Fig. 1a. It indicates that the product is composed of uniform particles with an average diameter of 70 nm. These particles are dispersed without aggregation. The electron diffraction (ED) pattern shows that they are amorphous. The TEM

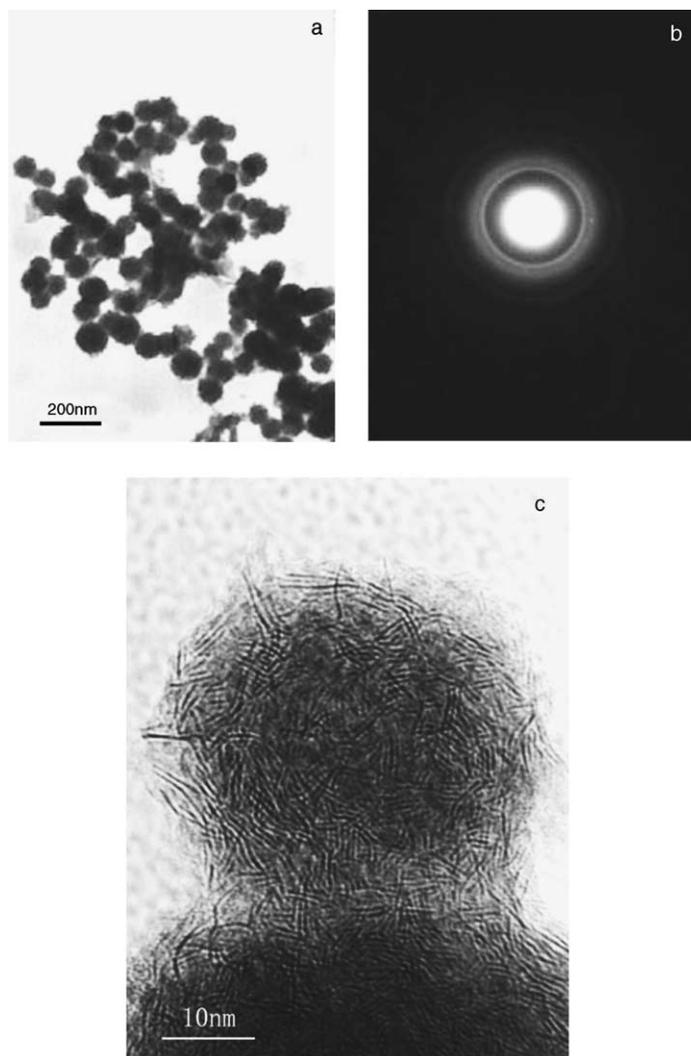


Fig. 1. TEM images of MoS₂: (a) prepared at 180 °C; (b) the electron diffraction pattern of MoS₂ after annealing at 450 °C; (c) HREM image of the sample after annealing at 450 °C.

image of the sample after annealing at 450 °C was similar to Fig. 1a. It is obvious that the morphology and the size of the product are kept during the annealing process. The typical electron diffraction pattern (Fig. 1b) reveals the polycrystallinity of the annealed sample while all of the electron diffraction rings could be indexed to the pattern of 2H-MoS₂. Fig. 1c shows the high resolution image of the sample after annealing at 450 °C. Unlike the image of highly ordered planes of MoS₂ along the *c*-direction which is expected in the 2H-MoS₂, the micrograph of the sample exhibits domains of short-range layered arrays stacked in a fairly chaotic fashion. The stacking number varies from 2 to 6, and the interlayer distance is close to 0.6 nm, which corresponds to the (0 0 2) *d*-spacing of the 2H-MoS₂ lattice fringe [10]. This suggests that the MoS₂ constitutes a new morphology between amorphous material and the thermodynamically stable 2H allotrope.

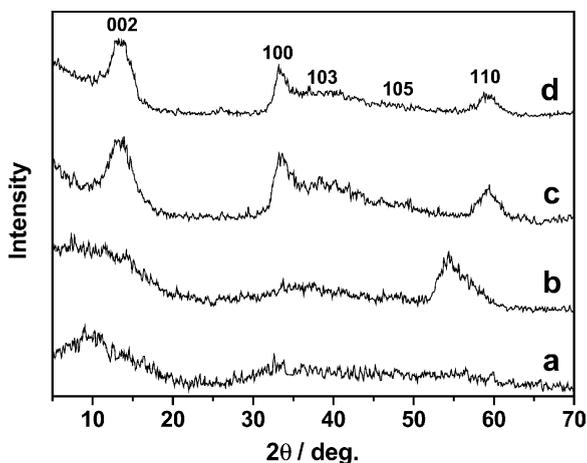


Fig. 2. X-ray diffraction pattern of MoS₂: (a) prepared at 180 °C; (b) annealed at 300 °C; (c) annealed at 450 °C; (d) annealed at 600 °C.

The disordered stacking was also demonstrated by the XRD analysis. Fig. 2a shows the XRD pattern of the product prepared at 180 °C for 16 h in the mixed solution of hydrazine and distilled water under hydrothermal conditions. As no obvious diffraction peak was recorded in the pattern the sample was virtually amorphous. The XRD patterns of the samples annealed at 300, 450 and 600 °C in a flow of argon are shown in Fig. 2b–d. At 300 °C, the (1 1 0) reflection emerged (Fig. 2b), though it shifts to lower angle. At 450 °C, three main diffracting lines are clearly observed (Fig. 2c). This XRD pattern is consistent with the literature report of the 2H-MoS₂ phase (JCPDS 37-1492) and can be indexed to a hexagonal cell with lattice parameters $a = 3.159$ and $c = 12.162$ Å. The XRD pattern of the sample annealed at 600 °C (Fig. 2d) is quite similar to Fig. 2c, indicating the relative stability of the crystallinity in an appropriate temperature range. The most pronounced evidence for the disordered stacking is the (1 0 0) reflection (Fig. 2c and d), which exhibits a characteristic sawtooth shape comprising asymmetrically broadened peaks [17]. Besides, the near-absence of the (1 0 3) and (1 0 5) lines, the small (0 0 2) peaks as well as the strong diffuse background are also indicative of low stacking and highly disordered packing of 2H-MoS₂ layers [18].

XPS were also measured to derive composition information of the product. From the XPS spectra (Fig. 3), the binding energy values of the as-prepared MoS₂ are 231.6 eV for Mo (3d) and 161.6 eV for S (2p), which were close to previous report [19]. The quantification of the peaks gave the ratio of Mo:S of 1:2.1, close to the stoichiometry of MoS₂.

We found that higher temperature is helpful in crystallization of the product as well as for the formation of uniform particles. The experiment carried out at lower temperature (<160 °C) leads to a more amorphous product with an irregular shape. Hydrazine is another factor in the crystallization of MoS₂. Increasing the amount of hydrazine was beneficial for the crystallinity of the product. This was due to the large quantity of N₂, H₂, and NH₃ formed by the decomposition of hydrazine [16], which could produce high pressure in the autoclave. Changing the reaction time does not change the product significantly.

It is well known that MoS₂ has a layered, graphite-like structure consisting of S–Mo–S sandwiches held together by weak van der Waals forces. It is easy for alkali metals and organic bases to intercalate in the interlayer gaps, due to a large d-spacing between two layers [1]. In our experimental conditions,

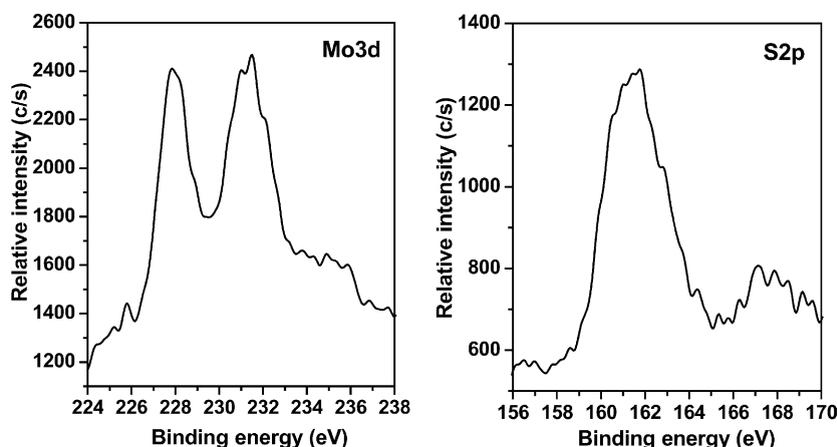


Fig. 3. XPS curves of the sample prepared at 180 °C.

H₂O and NH₃ may be inserted. The interaction between the inserted substances and the MoS₂ layers became strong under high pressure, which prevented the layers from stacking, and thus caused the limited number of these layers. Besides, the reduction step with N₂H₄ is a rapid one, thus, the time is too short to allow for particles to transfer to appropriate positions. As a spherical shape is optimal from an energetic point of view [20], disordered stacking of MoS₂ particles precipitated from the mixed solution of hydrazine and water in the autoclave.

To verify the above-proposed mechanism, a series of experiments were performed. When N₂H₄ was absent, brown MoS₃ precipitated from the solution together with a trace of MoS₂ after 14 h. Addition of hydrazine (10 ml) to the solution containing MoS₃ produced precipitation of molybdenum sulfide powders in 2 h. Obviously, the step of reduction with N₂H₄ is faster than the step of forming precursor (NH₄)₂Mo₃S₁₃. If H₂O was absent, the precursor could not completely dissolve in hydrazine. If the reaction was carried out at 100 °C without using an autoclave, the initial solution gave no MoS₂ precipitation.

4. Conclusions

This work describes a simple route leading to molybdenum disulfide with special morphology and properties. The product is composed of uniform (ca. 70 nm) particles, consisting of randomly and loosely stacked MoS₂ layers. This disordered stacking was also confirmed by XRD analysis. The reaction conditions and the formation mechanism were explored. The intercalation of H₂O and NH₃ as well as the rapid step of reduction with hydrazine may explain the morphological formation. This method is expected to apply for the preparation of other layered chalcogenides.

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